

Docket No.: LMPY-11310

## UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 2881

Examiner:

Serial No.: 09/771,013

Filed: January 25, 2001

In re Application of: Klaus Vogler, et al.

For:

ENERGY MONITOR FOR MOLECULAR FLUORINE LASER

Certificate of Mailing

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## INFORMATION DISCLOSURE STATEMENT

**Director of Patents** Washington, D.C. 20231

Dear Sir:

Each item of information listed in the attached FORM PTO-1449, for which a copy of each is attached, may be material to the examination of the above-identified application and is, therefore, submitted in compliance with the duty of disclosure defined in 37 CFR §§1.56, 1.97 and 1.98. The Examiner is requested to make these items of official record in this application.

This Information Disclosure Statement under 37 CFR §§1.56, 1.97 and 1.98 is not to be construed as a representation that a search has been made, that additional information material to the examination of this application does not exist, or that any one or more of these items constitutes prior art.

Serial No.: 09/771,013

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### This statement is filed pursuant to:

#### (x) 37 C.F.R. §1.97(b).

This information disclosure statement is filed either (1) within three months of the filing date of the national applications; (2) within three months of the date of entry of the national stage as set forth in 37 C.F.R. §1.491 in an international application; or (3) before the mailing date of a first office action on the merits, whichever event occurs last.

Accordingly, this information disclosure statement requires no fee and no certification.

#### ( ) 37 C.F.R. §1.97(c).

This information disclosure statement is filed after the period specified in 37 C.F.R. §1.97(b), but before the mailing date of either (1) a final action under 37 C.F.R. §1.113 or (2) a notice of allowance under 37 C.F.R. §1.311.

Accordingly, this information disclosure statement requires either the fee specified in 37 C.F.R. § 1.17 (p) for submission of an information disclosure statement under 37 C.F.R. §1.97(c) (\$240), or a certification according to 37 C.F.R. §1.97(e).

#### ( ) 37 C.F.R. §1.97(d).

This information disclosure statement is filed after the period specified in 37 C.F.R. §1.97(c).

Accordingly, this information disclosure statement requires the petition fee specified in 37 C.F.R. §1.17(i) (1) to consider an information disclosure statement under 37 C.F.R. § 1.97(d) (\$130), a certification according to 37 C.F.R. §1.97(e), and a petition requesting consideration of the information disclosure statement.

If this statement crosses in the mail with an office action, or is otherwise not in the indicated category of 37 C.F.R. §1.97, it is respectfully requested that this statement be treated in the next appropriate category and made of record. To the extent required, please treat this paper as a conditional petition for acceptance of the information disclosure statement.

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### (X) No fee is due

- ( ) The fee specified in 37 C.F.R. §1.17(p) for submission of an information disclosure statement under 37 C.F.R. §1.97(c) is enclosed (\$240).
- () The petition fee specified in 37 C.F.R. § 1.17(i) (1) to consider an information disclosure statement under 37 C.F.R. § 1.97(d) is enclosed (\$130.00).

Please charge any additional required fee or credit any overpayment to our deposit account number 50-0612. An additional copy of this page is enclosed.

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# Pursuant to 37 C.F.R. §1.97(e), I certify:

- (X) No certification is necessary.
- () Each item of information contained in the information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the statement.
- () (2) No item of information contained in the information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application, or, to my knowledge after making reasonable inquiry, was known to any individual designated in 37 C.F.R. §1.56(c), more than three months prior to the filing of the statement.

Respectfully submitted, SIERRA PATENT GROUP, LTD.

Dated: 1-7-02

Andrew V. Smith Reg. No. 43,132

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Sierra Patent Group, Ltd. P.O. Box 6149 Stateline, NV 89449 (775) 586-9500

Filed: January 25, 2001 Group: 2881

Form PTO 1449 Atty. Docket No. Serial No. (Rev. 2-32) U.S. Department of Commerce Patent and Trademark Office LMPY-11310 09/771,013 Onfo puation Disclosure Statement by Applicant Applicant: Klaus Vogler, et al. se several sheets if necessary)

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Examiner				Date Cons	idered	

Examiner: Initial if citation considered, whether or not citation is in conference with MPEP 609; Draw line through citation if not conformance and not considered. Include a copy of this form with the next communication to applicant.

Form PTO 1449

(Rev. 2-32)

U.S. Department of Commerce

Paper and Trademark Office

LMPY-11310

Information disclosure Statement by Applicant

Klaus Vogler, et al.

Filed: January 25, 2001 Group: 2881

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	5,247,531	9/21/93	Müller-Horsche, Elmar	372	38	3/12/92
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nit.	Document No.	Date	Name		Class	Subclass	Filing Date	
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	Hei 3-166784	7/18/91	Japan		H01S	3/134	X	
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ot conforman	ice and not considered. Inc	lude a copy of	of this form with the n	ext comm	unication to app	olicant.		

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PE	Patent and Trademark Office	LMPY-11310	09/771,013				
Inf	Formation Disclosure Statement by Applicant	Applicant:					
9 MIR ES		Klaus Vogler, et al.					
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